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Research Progress of CO₂ Capture and Utilization in Chemical Engineering

Guest Editors:

Dr. Jiawei Hu

Dr. Jiawei Zhong

Dr. Guanghui Zhang

Dr. Tianjia Chen

Dr. Qingxiang Ma

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Message from the Guest Editors

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Contributions within the following topics are welcome, but not limited to them:

- novel processes in CO₂ capture and utilization;
- advanced materials and technologies for CO₂ adsorption and separation;
- advanced catalysts and technologies for CO₂ conversion;
- novel theory and calculation methods in CO₂ capture and utilization.











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Editor-in-Chief

Prof. Dr. Giancarlo Cravotto

Department of Drug Science and Technology, University of Turin, Via P. Giuria 9, 10125 Turin, Italy

Message from the Editor-in-Chief

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